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Facile synthesis of $\text{NiS}_2@\text{MoS}_2$ core–shell nanospheres for effective enhancement in microwave absorption†

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Core–shell structured $\text{NiS}_2@\text{MoS}_2$ nanospheres have been successfully fabricated via a facile hydrothermal method. The structure and morphology of the nanospheres were characterized by X-ray diffraction (XRD), X-ray photoelectron spectroscopy (XPS), scanning electron microscopy (SEM), field emission scanning electron microscopy (FESEM) and transmission electron microscopy (TEM). The results indicated that this unique core–shell structure was beneficial to high-performance microwave absorption. A possible absorption mechanism was explained in detail. As an absorber, nanocomposites with a filler loading of 20 wt% exhibited enhanced microwave absorption properties due to characteristic impedance matching, synergistic effects, dipole and interface polarization, multiple reflections and quarter-wavelength matching. The minimum reflection loss can reach -41.05 dB at 12.08 GHz, and the absorption bandwidth exceeding -10 dB is 4.4 GHz with a thickness of 2.2 mm.

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Introduction

Nowadays, it is essential to exploit new and highly efficient microwave absorbers against electromagnetic (EM) radiation caused by electronic apparatus or radar systems, which will lead to undesirable EM pollution.^{1–3} Significant effort has been devoted to designing enhanced microwave absorbers with different morphologies and structures.^{4–6} Nanomaterials are attracting considerable attention in a variety of fields such as lithium-ion batteries,⁷ supercapacitors,^{8–10} energy storage,¹¹ and electrocatalysts for the oxygen reduction reaction and the hydrogen evolution reaction,^{12,13} as well as EM wave absorbers due to their diverse structural types, abundant and inexpensive nature, especially for metal sulfides. To date, various metal sulfides such as MoS_2 nanosheets,¹⁴ 3D MoS_2 nanospheres,¹⁵ hierarchical CuS nanospheres,^{16,17} CdS nanocrystals,¹⁸ Bi_2S_3 nanorods¹⁹ and CuS nanoflakes²⁰ have been utilized as EM wave absorbing materials.

As is well known, nano-structural engineering is beneficial to improving microwave absorption property. Recently, extensive studies have proved that a variety of nanomaterials with core–

shell or yolk–shell structure can be used as high-performance microwave absorbers due to the synergistic effects of both the cores and shells. Compared to single type of wave absorber, multi-components always exhibit much stronger reflection loss. For example, Xu *et al.*²¹ investigated the microwave absorption performance of ellipsoidal $\text{Fe}_3\text{O}_4@\text{CuSiO}_3$ nanorattles with different aspect ratios. Because of the strong magnetic loss and improvement of dielectric loss, they exhibited enhanced microwave absorption property with a minimum reflection loss of -30.8 dB at 8.0 GHz. Liu *et al.*⁴ fabricated $\text{CoNi}@\text{SiO}_2$ core–shell, $\text{CoNi}@\text{SiO}_2@\text{TiO}_2$ core–shell–shell and $\text{CoNi}@\text{Air}@\text{TiO}_2$ yolk–shell microspheres in a facile process and investigated their microwave absorption properties, respectively. The results showed that the $\text{CoNi}@\text{SiO}_2@\text{TiO}_2$ absorbers exhibited the most enhanced microwave absorption ability. In addition, the research about hierarchical $\text{Fe}_3\text{O}_4@\text{TiO}_2$ yolk–shell microspheres,²² yolk–shell $\text{C}@\text{C}$ microspheres,²³ $\text{FeSn}_2/\text{Sn}/\text{graphite}$ core–shell nanoparticles,²⁴ yolk–shell $\text{Fe}_3\text{O}_4@\text{ZrO}_2$ structure,²⁵ double-shelled $\text{Fe}_3\text{O}_4@\text{SnO}_2$ yolk–shell microspheres,²⁶ $\text{Fe}_3\text{O}_4/\text{C}$ core–shell nanospindles,²⁷ $\text{Ni}@\text{TiO}_2$ and $\text{Ni}@\text{SiO}_2$ core–shell microspheres²⁸ *et al.* has further verified that the core–shell or yolk–shell structure is beneficial to obtaining higher microwave absorption performance.

As for these core–shell or yolk–shell structural wave absorbers, the agglomeration of magnetic core or complicated preparation method restricts their practical application immensely. In order to solve these problems, using metal sulfides is more promising for EM wave absorption property on account of their typical dielectric loss mechanism. Furthermore, reports on core–shell nanostructural wave absorbers

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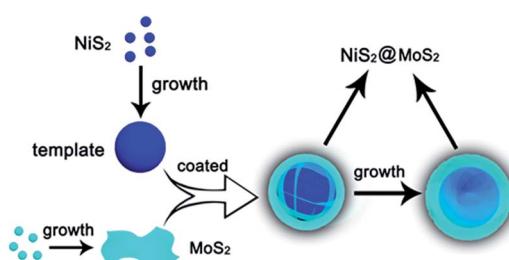


composed of transition metal sulfides are still scarce. Based on this, we demonstrate the successful design and fabrication of uniform core-shell $\text{NiS}_2@ \text{MoS}_2$ microspheres through a facile hydrothermal route with enhanced microwave absorption performance for the first time. As expected, the synthesized $\text{NiS}_2@ \text{MoS}_2$ microspheres exhibits excellent wave absorption property compared with that of single NiS_2 or MoS_2 nanomaterial.

Results and discussion

As shown in Scheme 1, the NiS_2 nanospheres have been fabricated by a simple solvothermal method. After that, the NiS_2 nanospheres could play the role of nucleation site for MoS_2 . The generated MoS_2 nanoplates coated on the surface of NiS_2 nanospheres due to the strong affinity which caused by homologous inorganic molecules between the nucleation sites and MoS_2 nanoplates to form core-shell structural $\text{NiS}_2@ \text{MoS}_2$ nanospheres. The wrinkled nanoplates would increase the specific surface area that is beneficial to obtain higher microwave absorption performance.

In order to study the crystal structure of NiS_2 and $\text{NiS}_2@ \text{MoS}_2$ nanospheres, the XRD patterns have been provided in Fig. 1a. It can be seen that all the diffraction peaks are readily indexed to the cubic vaesite (JCPDS no. 11-0099). The narrow sharp peaks confirm that the material should be highly crystallized NiS_2 without any other impurities. In addition, the XRD pattern of $\text{NiS}_2@ \text{MoS}_2$ nanospheres is almost the same as that of NiS_2 nanospheres, while the intensity of peaks become weaker due to the coated MoS_2 nanoplate. The XRD pattern of MoS_2 nanoplate shown in Fig. S1† indicates that the MoS_2 nanoplate is weak crystalline and the intensity of peaks is far lower than that of NiS_2 nanospheres. As a result, the XRD peaks of MoS_2 nanoplate cannot be displayed in the pattern of $\text{NiS}_2@ \text{MoS}_2$ nanospheres. To verify the existence of MoS_2 , the surface chemical states of $\text{NiS}_2@ \text{MoS}_2$ nanospheres are further investigated *via* the X-ray photoelectron spectroscopy (XPS). The core level of the Ni 2p spectrum shown in Fig. 1b can be deconvoluted into two spin-orbit doublets. The peaks at 857.37 and 875.38 eV are attributed to $2p_{3/2}$ and $2p_{1/2}$ of Ni^{2+} , and the peaks at 861.67 and 880.38 eV are assigned to $2p_{3/2}$ and $2p_{1/2}$ of Ni^{3+} , respectively. The existence of Ni^{3+} is mainly due to the slight oxidation of NiS_2 on the surface.²⁹ From the Mo 3d spectrum, it certainly turns out that the Mo atom exists as +4



Scheme 1 Schematic illustration of the synthetic procedure for the $\text{NiS}_2@ \text{MoS}_2$ nanospheres.

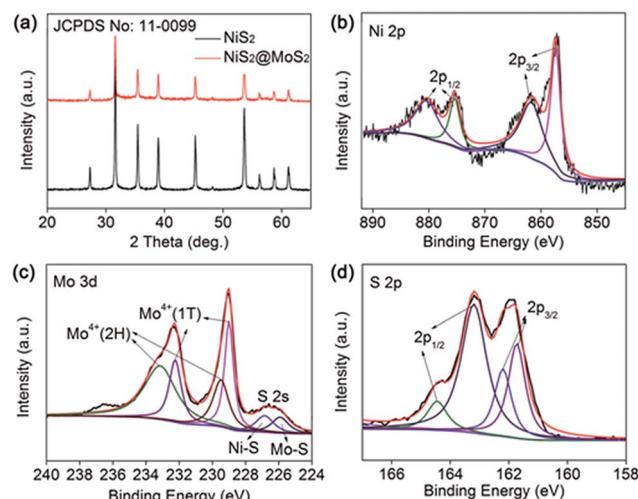


Fig. 1 (a) XRD pattern of NiS_2 and $\text{NiS}_2@ \text{MoS}_2$ nanospheres; XPS spectra of (b) Ni 2p, (c) Mo 3d, (d) S 2p.

oxidation state. The two peaks at 233.12 eV ($\text{Mo}^{4+} 3d_{3/2}$) and 229.46 eV ($\text{Mo}^{4+} 3d_{5/2}$) are from the semiconducting 2H-phase MoS_2 , and those at 232.22 eV ($\text{Mo}^{4+} 3d_{3/2}$) and 228.98 eV ($\text{Mo}^{4+} 3d_{5/2}$) are assigned to metallic 1T-phase MoS_2 .³⁰ In addition, the nearby S 2s peaks are deconvoluted into two peaks at 226.83 and 225.90 eV, corresponding to the two chemical states of S species bonding with Ni and Mo ions (Fig. 1c). For the S 2p spectra (Fig. 1d), the XPS peak is deconvoluted into four peaks. The peaks at 164.45 and 162.19 eV are assigned to the S $2p_{1/2}$ and S $2p_{3/2}$ orbitals of divalent sulfide ions (S^{2-}) in MoS_2 , while the other two peaks at 163.18 and 161.71 eV are attributed to S $2p_{1/2}$ and S $2p_{3/2}$ of Ni-S bondings. Therefore, the XPS characterization have indicated the successful synthesis of $\text{NiS}_2@ \text{MoS}_2$ core-shell nanostructures and suggested a strong interaction between these two phases.³¹

The sizes and morphologies of the as-synthesized NiS_2 and $\text{NiS}_2@ \text{MoS}_2$ nanospheres were characterized by SEM and TEM. An overview of SEM images (Fig. 2a and b) show the surface

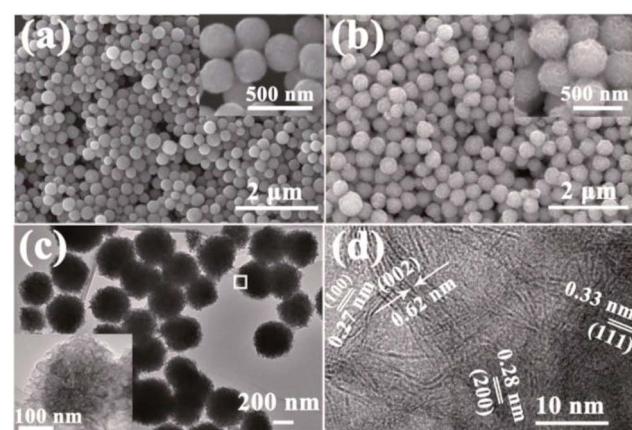


Fig. 2 SEM images of (a) NiS_2 and (b) $\text{NiS}_2@ \text{MoS}_2$ nanospheres. Inset: magnified SEM images; (c) TEM image; (d) high-resolution TEM image of $\text{NiS}_2@ \text{MoS}_2$ nanospheres.

morphology, indicating that the particles exhibit uniform nanospheres with smooth or wrinkled surface. A magnified SEM images insetted in Fig. 2a and b reveal that the average diameter of these two samples are about in the range of 200–250 nm and 250–300 nm. To verify the core–shell structure of $\text{NiS}_2@\text{MoS}_2$ nanospheres, the TEM and HRTEM images have been provided in Fig. 2c and d. From the TEM image, it is obviously seen that the solid sphere as core and the curved nanoplates as shell. And the nanoplate-assembled layer is about 25 nm. As shown in Fig. 2d, the ordered lattice fringes are clearly observed from a high-resolution TEM image. The spacings between two neighboring lattice fringes are approximately 0.62 nm and 0.27 nm, corresponding to the (002) and (100) plane of MoS_2 shell. Then for NiS_2 core, the spacings between two neighboring lattice fringes are approximately 0.33 nm and 0.28 nm, corresponding to the (111) and (200) plane, respectively. Moreover, the FESEM images of $\text{NiS}_2@\text{MoS}_2$ nanospheres presented in Fig. S2[†] reveal the NiS_2 core and MoS_2 shell explicitly.

To further illuminate the core–shell structure of $\text{NiS}_2@\text{MoS}_2$ nanospheres, the FESEM characterization and the corresponding elemental maps have been displayed in Fig. 3. In the rectangular region, the elemental maps of S, Ni and Mo demonstrate that the $\text{NiS}_2@\text{MoS}_2$ nanospheres are composed of NiS_2 core and MoS_2 shell indeed. Moreover, as shown in Fig. S3,[†] the elemental mapping of S, Ni and Mo elements in line-scanning mode and atomic percent correspond to this result. The unique structure is helpful for the high-efficiency electromagnetic-wave absorption property.

It is very interesting that the coated state will become very different with variable quantity of sodium molybdate and L-cysteine. As shown in Fig. 4, when the amount of sodium molybdate and L-cysteine decrease to half of the original (0.04 g and 0.08 g), only a little nanoplate coated on the surface of NiS_2 nanospheres. On the other hand, when their amounts increase

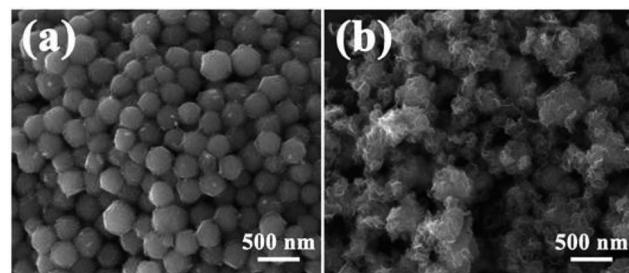


Fig. 4 FESEM images of $\text{NiS}_2@\text{MoS}_2$ samples under different conditions: (a) $\text{Na}_2\text{MoO}_4 \cdot 2\text{H}_2\text{O}$: 0.04 g, L-cysteine: 0.08 g; (b) $\text{Na}_2\text{MoO}_4 \cdot 2\text{H}_2\text{O}$: 0.16 g, L-cysteine: 0.32 g.

twice compared to the original amount (0.16 g and 0.32 g), much redundant MoS_2 nanoplates generate. These results indicate that, with proper control of the relative ratios of sodium molybdate to NiS_2 nanospheres, core–shell structural $\text{NiS}_2@\text{MoS}_2$ nanospheres can be successfully fabricated.

The electromagnetic wave absorption properties of NiS_2 and $\text{NiS}_2@\text{MoS}_2$ nanospheres are investigated in terms of reflection loss. According to the transmission line theory, the reflection loss (RL) values are calculated using the measured data of relative permittivity and permeability at a given frequency and thickness layer, which is summarized by the following equations:³²

$$z_{\text{in}} = \sqrt{\frac{\mu_r}{\epsilon_r}} \tanh \left[j \left(\frac{2f\pi d}{c} \right) \sqrt{\mu_r \epsilon_r} \right] \quad (1)$$

$$\text{RL} = 20 \log \left| \frac{Z_{\text{in}} - Z_0}{Z_{\text{in}} + Z_0} \right| \quad (2)$$

where, ϵ_r and μ_r (for NiS_2 and $\text{NiS}_2@\text{MoS}_2$, μ_r is thought as 1) are the complex permittivity and permeability of the composite absorber, respectively; f is the frequency; d is the thickness of the absorber, and c is the velocity of light in free space; Z_{in} is the input characteristic impedance, Z_0 is the impedance of free space. Fig. 5a shows the RLs of MoS_2/PVDF , NiS_2/PVDF and $\text{NiS}_2@\text{MoS}_2/\text{PVDF}$ with different loadings at a thickness of 2.2 mm. It is found that the minimum RL value of $\text{NiS}_2@\text{MoS}_2/\text{PVDF}$ with 20 wt% loading decreases rapidly to -41.05 dB at 12.08 GHz, whereas that of MoS_2/PVDF and NiS_2/PVDF are -12.47 dB at 15.52 GHz and -15.40 dB at 14.40 GHz under the same loadings. As for $\text{NiS}_2@\text{MoS}_2/\text{PVDF}$, when the filler loading decreased to 10 wt% or increased to 30 wt%, the minimum RL value is far less than that of 20 wt%, indicating that the optimum loading is 20 wt%. As shown in Fig. S4,[†] the RL value of $\text{NiS}_2@\text{MoS}_2/\text{PVDF}$ with 20 wt% loading varies with the thickness. In addition, $\text{NiS}_2@\text{MoS}_2/\text{PVDF}$ with 20 wt% loading exhibits a wide frequency bandwidth of effective attenuation ($\text{RL} < -10$ dB) up to 4.40 GHz (10.16–14.56 GHz). Fig. 5b–d show three dimensional plots of calculated theoretical RLs of $\text{NiS}_2@\text{MoS}_2/\text{PVDF}$ versus the frequency and thickness at different loadings. This indicates the microwave absorption property at different frequencies can be tuned greatly by controlling the thickness and the filler contents of the absorbers.

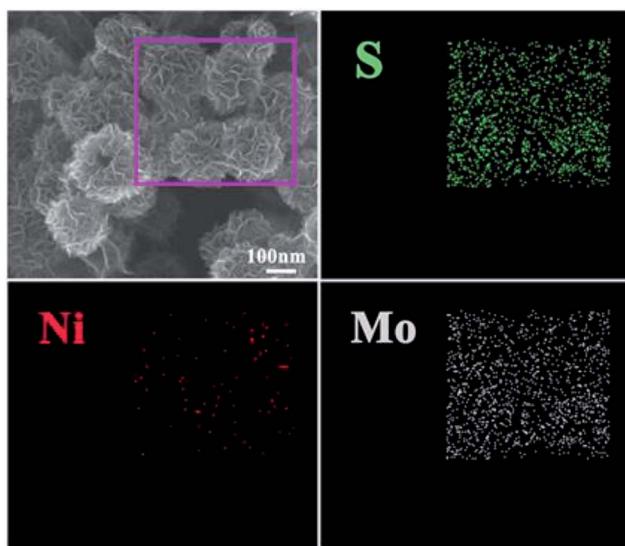


Fig. 3 FESEM image of the $\text{NiS}_2@\text{MoS}_2$ nanospheres and corresponding elemental mapping images of S, Ni and Mo.

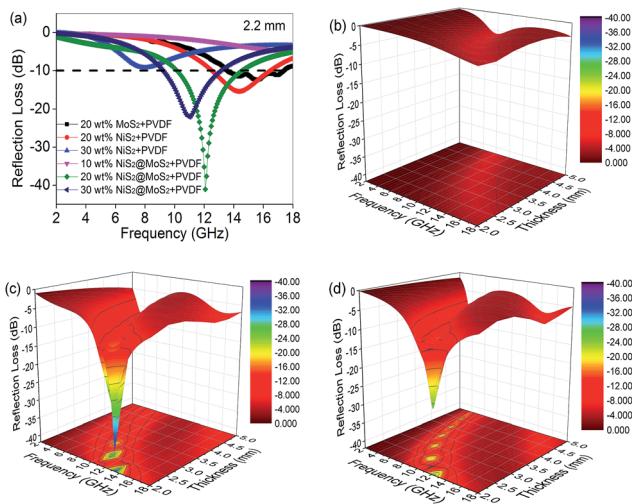


Fig. 5 (a) Microwave RL curves of the composites with a thickness of 2.2 mm in the frequency range of 2–18 GHz. Three-dimensional representations of the RL of NiS₂@MoS₂/PVDF composites with a filler loading of (b) 10 wt%, (c) 20 wt% and (d) 30 wt%.

It is well-known that the electromagnetic wave absorption performance is closely correlated with their complex relative permittivity and permeability, where the real parts of complex permittivity (ϵ') and complex permeability (μ') represent the storage capability of electric and magnetic energy, and imaginary parts (ϵ'' and μ'') stand for the dissipation capability of these two types of energy. Owing to the absence of magnetic components in NiS₂ and MoS₂, the complex permeability can be ignored. To reveal the microwave absorption mechanism, Fig. 6 shows the complex permittivity of NiS₂/PVDF, MoS₂/PVDF and NiS₂@MoS₂/PVDF nanocomposites. It is observed that the core-shell structure has an important impact on the electromagnetic parameters. The NiS₂ nanospheres exhibit relatively high complex permittivity without external MoS₂ shells. As shown in Fig. 6a and S4,[†] the ϵ' and ϵ'' of 30 wt% NiS₂/PVDF decreases from 26.5 to 12.6 and from 13.5 to 9.0 with the increase of frequency, which is much higher than that of NiS₂@MoS₂/PVDF under the same filler loading. The excessive ϵ' and ϵ'' is not good for characteristic impedance match. As aforementioned, NiS₂ and NiS₂@MoS₂ nanospheres have negligible magnetic loss mechanism, therefore the incident EM wave is attenuated due to single dielectric loss mechanism. The dielectric losses are

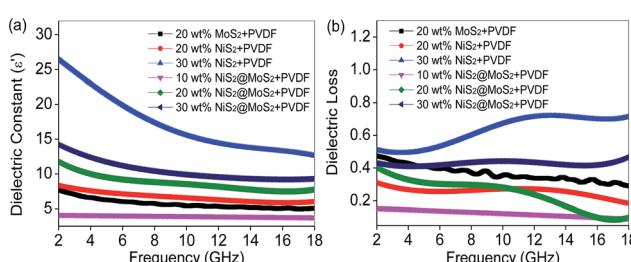


Fig. 6 Frequency dependence on (a) real part of the complex permittivity and (b) dielectric loss of samples in the frequency range 2–18 GHz.

mainly originated from the electron polarization, the ion polarization and the electric dipole polarization, *etc*. However, in the microwave range, the electron polarization and the ion polarization are insignificant, while the electric dipole polarization might be a main contributor.²⁴ In theory, the tangent of dielectric loss angle (δ_e) of the material can be expressed as $\tan \delta_e = \epsilon''/\epsilon'$. Fig. 6b displays that the $\tan \delta_e$ value of 30 wt% NiS₂/PVDF is highest between 0.49 to 0.72 in frequency range of 2–18 GHz. It is unfortunate that the preferable $\tan \delta_e$ in NiS₂/PVDF fail to endow it with excellent microwave absorption on account of the mismatched characteristic impedance. The 20 wt% NiS₂@MoS₂/PVDF shows the most enhanced EM wave absorption property while the $\tan \delta_e$ value decreases from 0.40 to 0.09 with increasing frequency. This phenomenon indicates that the matched characteristic impedance is not the only influence factor. To illustrate the impact of core–shell structure on microwave absorption performance, we summarized the corresponding performances in Table 1. All these research has proved that the core–shell structure is beneficial for strong wave absorption ability.

In terms of the quarter-wavelength matching model, the relationship between the predicted matching thickness (t_m) and the corresponding matching frequency (f_m) can be described by the following equation:³⁷

$$f_m = \frac{nc}{4t_m \sqrt{|\epsilon_r||\mu_r|}} \quad (n = 1, 3, 5, \dots) \quad (3)$$

Based on eqn (2), when Z_{in} is close to Z_0 , the optimal absorption performance of absorber can be achieved. According to previous study,³⁸ when the matching thickness of the samples satisfies eqn (3), $Z = |Z_{in}/Z_0|$ is close to 1. Therefore, the minimum RL value can be obtained when the relationship between matching thickness and matching frequency of the absorbers satisfies eqn (3). As mentioned before, the minimum RL value of 20 wt% NiS₂@MoS₂/PVDF appears at 12.08 GHz under the thickness of 2.2 mm. Using eqn (3), the calculated thickness is 2.15 mm, which is very close to the theoretical thickness of 2.2 mm that is corresponding to wavelength of $\lambda/4$. It turns out that the quarter-wavelength matching theory plays an important role. Another key factor that should be considered for an excellent absorber is the attenuation constant α , which determines the attenuation properties of materials, can be determined as:³⁹

$$\alpha = \frac{\sqrt{2\pi f}}{c} \times \sqrt{\mu''\epsilon'' - \mu'\epsilon' + \sqrt{(\mu''\epsilon'' - \mu'\epsilon')^2 + (\mu'\epsilon'' + \mu''\epsilon')^2}} \quad (4)$$

where f is the frequency of electromagnetic wave and c is the velocity of light. In general, the larger attenuation constant will result in more dielectric loss, which is beneficial to wave absorption performance. Fig. 7 gives the frequency dependence of attenuation constant α for samples. It is observed that the 30 wt% NiS₂/PVDF composites possess the largest attenuation constant among these samples in the measured frequency range while their wave absorption property is not the best. And the attenuation constant of NiS₂@MoS₂/PVDF composites with

Table 1 Comparison of the microwave absorption properties about other core–shell structural nanomaterials

Sample	Minimum RL value (dB)	Thickness (mm)	Filler loading (wt%)	Effective bandwidth (<−10 dB) (GHz)	Ref.
PPy@PANI	−34.80	2.0	50.0	4.7	33
C@C	−34.80	2.0	50.0	5.4	23
α -MoO ₃ @PANI	−33.70	2.0	10.0	4.0	34
Fe ₃ O ₄ @Cu Silicate	−30.80	2.0	16.7	3.5	21
Fe ₃ O ₄ @SnO ₂	−36.50	2.0	16.7	16.0	26
Ni@SiO ₂	−40.00	1.5	70.0	3.5	28
Ni@TiO ₂	−35.40	4.0	70.0	1.0	28
Cu@ZnO	−26.70	3.0	—	1.5	35
NiCu alloys	−31.13	1.5	40.0	3.0	36
FeSn ₂ @Sn@C	−28.00	3.3	50.0	7.5	24
This work	−41.05	2.2	20.0	4.4	—

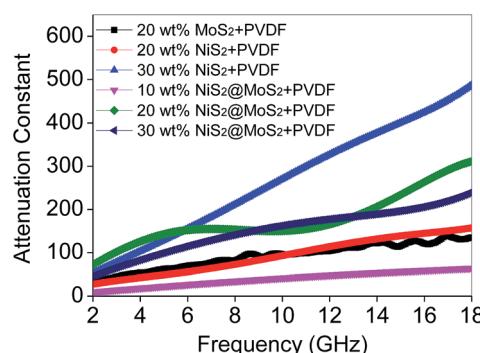
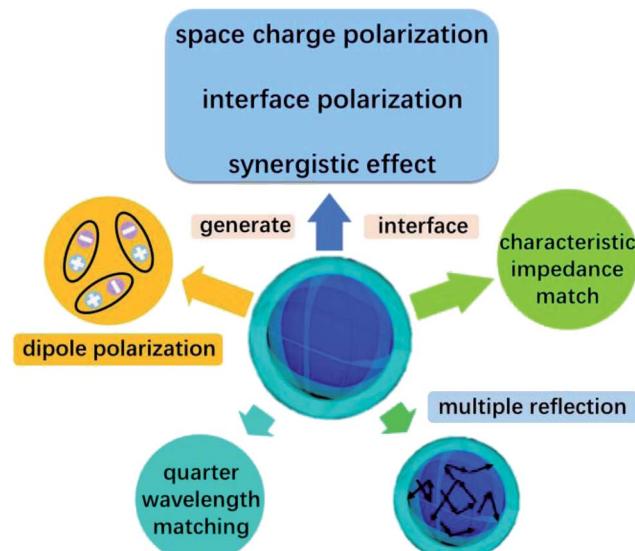


Fig. 7 Attenuation constant of various samples.

filler loading of 20 wt% is much higher than that of 10 wt% and 30 wt%. All these phenomenon has further proved that there are many factors affect the wave absorption performance.

Except for the characteristic impedance match and quarter-wavelength matching theory, it is well known that the core–shell structure of NiS₂@MoS₂ will generate multiple components and more interfaces, leading to a synergistic effect among NiS₂, MoS₂ and PVDF that is beneficial to improving wave absorption property. In the core–shell structure, surface charges tend to accumulate at the interfaces between two different dielectric media, resulting in dipole polarization. Under an external alternating EM field, the lag of induced charges that counter the increased frequency results in relaxation which is caused by the polarization of defects and transforms EM energy into heat energy.^{14,40}

In addition, after coating with MoS₂ shell, the original smooth surface of NiS₂ nanospheres turns into wrinkled one, generating larger surface area. Large surface areas can provide more active sites for dissipating and scattering microwaves.⁴¹ And according to our previous research about wave absorption performance of 3D MoS₂, it is concluded that the laminated structure is able to make the incident microwave generate multiple reflection between the different layers, which will extend the propagation path of electromagnetic wave and greatly enhance their EM wave absorption ability.⁴² Furthermore, the high-curvature surfaces will lead to more remarkable interface polarization compared with spherical nanoparticles.²¹

Scheme 2 The possible wave absorption mechanism of NiS₂@MoS₂/PVDF nanocomposites.

On the basis of the above discussion, the excellent microwave absorption performance of NiS₂@MoS₂/PVDF is mainly attributed to the unique core–shell structure of NiS₂@MoS₂ nanospheres which causes characteristic impedance match, synergistic effect among NiS₂, MoS₂ and PVDF, dipole polarization, interface polarization and multiple reflection. Besides, the quarter-wavelength matching theory is another important wave absorption mechanism. All these mechanism of enhanced microwave absorption have been displayed in Scheme 2 intuitively.

Experimental

All chemical reagents were purchased from Lanyi Chemical Company. And all were of analytical grade and used without further purification.

Preparation of NiS₂ nanospheres

In a typical synthesis, 0.5704 g of nickel chloride hexahydrate (NiCl₂·6H₂O) and 0.128 g of sulfur powder were dispersed into



60 mL of ethylene glycol (EG) by stirring for 20 min. Then 0.96 g of polyvinyl pyrrolidone (PVP-40 000) was added. After stirring for another 30 min, the homogeneous suspension was transferred into Teflon-lined stainless steel autoclave (100 mL). After reacting in 200 °C for 12 h, the solution was cooled to room temperature. The resultant black precipitate of NiS₂ nanospheres was washed several times with distilled water and absolute ethanol and finally dried at 60 °C for 12 h for further characterization.

Preparation of core-shell NiS₂@MoS₂ nanospheres

The core-shell NiS₂@MoS₂ nanospheres was prepared *via* a facile hydrothermal method. 0.1 g synthesized NiS₂ powder was dispersed into 50 mL of de-ionized water. Then 0.08 g of sodium molybdate (Na₂MoO₄·2H₂O) and 0.16 g of L-cysteine were added. After stirring for 10 min, the homogeneous suspension was transferred into Teflon-lined stainless steel autoclave (100 mL) and reacted in 200 °C for 12 h. The resultant black precipitate of NiS₂@MoS₂ nanospheres was washed several times with distilled water and absolute ethanol and finally dried at 60 °C for 12 h for further characterization. MoS₂ nanoplate has been fabricated by the same method without adding NiS₂ powder.

Characterization

XRD analyses were carried out on an X-ray diffractometer (D/MAX-1200, Rigaku Denki Co. Ltd., Japan). The XRD patterns with Cu K α radiation ($\lambda = 1.5406$ Å) at 40 kV and 40 mA were recorded in the range of $2\theta = 5\text{--}80^\circ$. Scanning electron microscope (SEM) images were achieved by a FEI Quanta 250 field-emission gun environmental scanning electron microscope at 15 kV with the samples obtained from the thick suspension dropping on the silicon slice. Field emission scanning electron microscopy (FE-SEM) on a JSM-6700F microscope. Transmission electron microscopy (TEM) and high-resolution TEM (HRTEM) investigations were carried out by a JEOL TEM-2100F microscope. X-ray photon spectroscopy was studied with a Thermo Scientific ESCALAB 250 Xi XPS system.

EM absorption measurement

The composites used for EM absorption measurement were prepared by mixing the synthesized NiS₂ nanospheres and core-shell NiS₂@MoS₂ nanospheres with polyvinylidene fluoride (PVDF) in different mass percentages, respectively. The mixtures were then pressed into cylindrical-shaped samples ($\Phi_{\text{out}} = 7.00$ mm and $\Phi_{\text{in}} = 3.04$ mm). The complex permittivity and permeability values were measured in the 2–18 GHz range with coaxial wire method by an Agilent N5230C PNA-L Network Analyzer.

Conclusions

In summary, with NiS₂ nanospheres as the cores and nucleation sites, core-shell NiS₂@MoS₂ nanocomposite have been successfully constructed through a very simple hydrothermal process. It is concluded that the NiS₂@MoS₂ nanocomposites

show substantially enhanced microwave absorption properties as compared to single NiS₂ nanospheres or MoS₂ nanoplates due to this core–shell structure. With only 20 wt% filler content, the minimum reflection loss of NiS₂@MoS₂/PVDF composites reaches -41.05 dB at 12.08 GHz with a thickness of 2.2 mm and the absorption bandwidths exceeding -10 dB are 4.4 GHz. Investigations on the mechanism of microwave absorption indicate that their high performance can be caused by characteristic impedance match, synergistic effect and dielectric loss. More importantly, the excellent microwave absorption properties are highly dependent on the quarter-wavelength matching theory. This work will be helpful for the design and development of new novel microwave absorbers with multiple component and unique nanostructure.

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